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INFORMATION DISCLOSURE STATEMENT BY APPLICANT	Application Number	08/903486				
(Use as many sheets as necessary)	Filing Date	July 29, 1997				
	First Named Inventor	Forbes, Leon CENED				
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Sheet 3 of 3	Attorney Docket No: 3	03.326US1

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Application Number	08/903,486
Filing Date	July 29, 1997
First Named Inventor	Forbes, Leonard
Group Art Unit	2811
Examiner Name	Kang, Donghee

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